

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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| In re: | DeSimone <i>et al.</i> | Confirmation No.: | 8879 |
| Appl No.: | 10/583,570 | Group Art Unit: | 1615 |
| Filed: | 3/5/07 | Examiner: | H. Sheikh |
| For: | METHODS FOR FABRICATING ISOLATED MICRO- AND NANO- STRUCTURES USING SOFT OR IMPRINT LITHOGRAPHY | | |

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

RESPONSE TO RESTRICTION REQUIREMENT

This is in response to the Office Action dated February 16, 2011, in which the Examiner has required an election of a Patterned Template Substrate: (a) Dual substrates (first and second substrate) (reads on claims 1, 2, 4, 5, 14-23, 25-31, 33, 34, 38-48 and 54-56); or (b) Single substrate (reads on claims 76, 78, 79, 88-99 and 103-111). Applicants hereby provisionally elect without traverse the species (a) Dual substrates. According to the MPEP, the species elected is where searching will begin, and the searching will be expanded to additional species or a genus until art is found. This election is not to be considered a disclaimer of any disclosed subject matter. Applicants expressly reserve the right to file divisional applications or take such other appropriate measures deemed necessary to protect all subject matter in the present application.

Request for Interview

Applicants believe that an interview between the Examiner, the undersigned representative and the Applicant(s) would advance the prosecution of this case. Therefore, Applicants respectfully would like to request an interview between the Examiner, the undersigned representative and the Applicant(s) at the Examiner's earliest convenience. The courtesy of a telephone call to the undersigned to discuss this before the issuance of a first Office Action is requested.